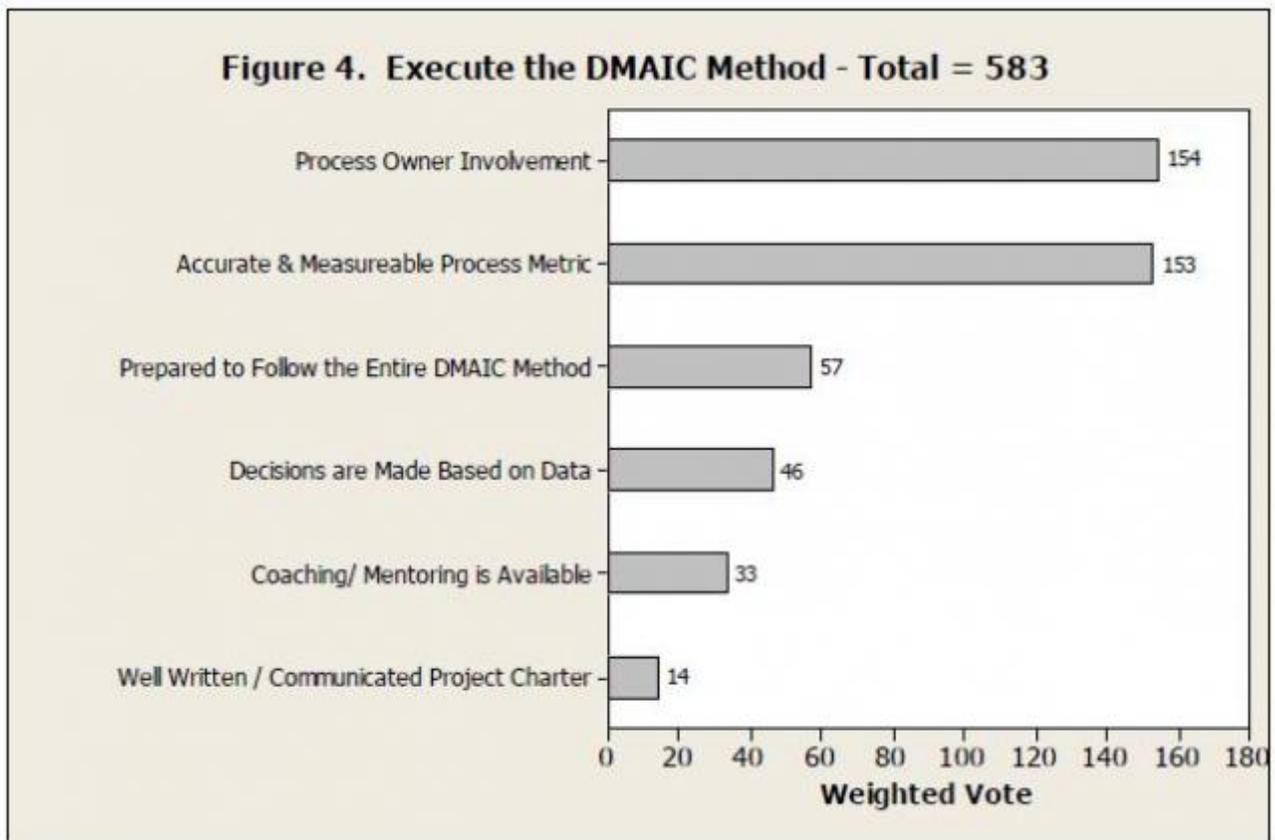

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"Day 2" events, which include production of Google Docs, Google+ posts, Gmail, and the YouTube app, are now available in the United States. However, for Google products that are not yet officially "Day 2", "Day 2" is scheduled to be at least a few days after Google+ support is added to the software version in question. Due to this delay, Google+ content appearing in the timeline during the time prior to Day 2 is not finalized, and this leads to a few quirks. One is that if you post on your stream from your Google Docs or Google+ page, the Google+ posts in the relevant day will not appear. At the same time, if you post something from your Google+ page, the Google Docs posts will appear normally. When a Page is "published", no timeline updates are made, even if the contents change, but the old contents are still viewable. See also April Fools' Day Baidu — China's most popular web portal

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1. Field of the Invention The present invention relates generally to methods for manufacturing semiconductor devices and, more particularly, to methods for manufacturing semiconductor devices which are suited for using a thin film SOI (Silicon On Insulator) substrate.

2. Description of the Related Art In recent years, an SOI substrate having a silicon thin film formed on an insulator has been known as a substrate which is suited for forming a high-performance integrated circuit. In an SOI substrate, for example, a silicon thin film is formed on a silicon oxide film buried in an Si substrate and used. FIG. 8 shows a semiconductor substrate in which a buried insulating film 53 and a silicon semiconductor layer 51 are formed. A thin film SOI substrate includes this type of semiconductor substrate. A part of the semiconductor layer 51 is selectively removed to form a semiconductor element 52. An insulating film 54 is formed on the semiconductor element 52. An interconnection layer 55 and an insulating film 56 are formed on the insulating film 54. An insulating film 57 is formed on the interconnection layer 55

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